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	Application No.	Applicant(s)	
AL 45	10/754,320	WONG, ROBERT C.	
Notice of Allowability	Examiner	Art Unit	
	Andy Huynh	2818	
The MAILING DATE of this communication apperall claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI	(OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject to	plication. If not include will be mailed in due	ed course. THIS
1. X This communication is responsive to the Amendment dated	d 04/18/05		
2. X The allowed claim(s) is/are <u>1-7 and 9-23.</u>			
3. $igotimes$ The drawings filed on <u>08 January 2004</u> are accepted by the	e Examiner.		
4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submin INFORMAL PATENT APPLICATION (PTO-152) which give (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date (b) Including such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in to the depo attached Examiner's comment regarding REQUIREMENT	e been received. been received in Application No cuments have been received in this of this communication to file a reply IENT of this application. itted. Note the attached EXAMINER es reason(s) why the oath or declara is be submitted. Son's Patent Drawing Review (PTO) s Amendment / Comment or in the Co. 84(c)) should be written on the drawithe header according to 37 CFR 1.121(sit of BIOLOGICAL MATERIAL	national stage applical complying with the recomplying attached. Office action of the left, and the left, and the submitted. It is not the left, and the submitted.	quirements IOTICE OF
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Attachment(s) 1. □ Notice of References Cited (PTO-892)	5. Notice of Informal F	Patent Application (PT	O-152)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	(PTO-413),	•
 Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date 04/18/05 	Paper No./Mail Da 08), 7 🗍 Examiner's Amend		
4. Examiner's Comment Regarding Requirement for Deposit	8. X Examiner's Statem	ent of Reasons for Allo	owance
of Biological Material	9. Other Andy t Patent	tugal Examina	
LLS Patent and Trademark Office	70 - 70		

DETAILED ACTION

In the Amendment dated April 18, 2005, claims 8 and 24 are canceled without prejudice and claims 1, 6, 14 and 15 are amended is acknowledged. Accordingly, claims 1-7 and 9-23 remain pending in the present application.

Allowable Subject Matter

Claims 1-7 and 9-23 are allowed.

The following is an examiner's statement of reason for allowance:

Claims 1-7 and 9-13 are allowable over the prior art of record because the prior art of record does not teach or render obvious a selective silicon-on-insulator (SOI) structure comprises a DC node diffusion region is located within bulk silicon without oxide underneath thereby the DC node diffusion region, and in combination with all other features as recited in independent claim 1.

Claim 14 is allowable over the prior art of record because the prior art of record does not teach or render obvious a integrated circuit comprises a DC node diffusion region is located within bulk silicon without oxide underneath thereby the DC node diffusion region, and in combination with all other features.

Claims 15-23 are allowable over the prior art of record because the prior art of record does not teach or render obvious a semiconductor substrate comprises a DC node diffusion region is located within bulk silicon without oxide underneath thereby the DC node diffusion region, and in combination with all other features as recited in independent claim 15.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh whose telephone number is (571) 272-1781. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Andy Huynh

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04/21/05

Patent Examiner